



Contact Information

John Pong
Nanonex Corporation
1-732-355-1600
jpong@nanonex.com

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*NANONEX DELIVERS ADVANCED NANOIMPRINT TOOL TO NIST
BECOMING THE LARGEST SUPPLIER TO US NATIONAL LABS*

Princeton, NJ, December 14, 2005: Nanonex Corporation, the leader in nanoimprint solution and applications with the longest history, announced today a delivery of Nanonex's advanced nanoimprinter, NX-2000 tool to the National Institute of Standards and Technology (NIST) in Gaithersburg, Maryland. This makes Nanonex the leading supplier of nanoimprint tools delivered to US National Labs. In addition to industry and overseas customers, other example of US national labs and universities that have purchased Nanonex nanoimprint tools include Sandia National Lab, National Nanotechnology Infrastructure Network's (NNIN) node at the University of California at Santa Barbara (UCSB), the University of Michigan, the University of Maryland, and Princeton University. Nanonex also has supplied nanoimprint materials (resists, functional materials, and molds) to over 50 customers, including over 80 shipments to users in USA, Canada, UK, France, Germany, Japan, Taiwan, Korea and Singapore.

The Nanonex NX-2000 delivered to NIST is a versatile nanoimprint tool for both uv and thermo imprinting, with an Air Cushion Press (ACPTM) for excellent imprint uniformity and yield over large area, and with a Smart Sample Holder for flexible imprinting of the molds and substrates having arbitrary shape and geometry (up to 6" diameter).

Larry Koecher, COO, Nanonex said "Nanonex is delighted to be the preferred supplier of nanoimprint tools to US national labs and universities"

About Nanonex Corp.

Nanonex, a pioneer and a leader in nanoimprint, provides a complete line of nanoimprint lithography (NIL) technology solutions including tools, masks, and processes. Based on its proprietary technologies, Nanonex NIL solutions offer sub 10 nm feature resolution, 3D patterning, large area uniformity, accurate overlay alignment, high-throughput, and low cost. Nanonex NIL solutions include all forms of nanoimprinting, such as thermoplastic, uv-curable, thermal curable, and direct imprinting (embossing). Nanonex NIL solutions can meet the needs of a broad spectrum of markets, such as optical devices, displays, data storage, biotech, IC, chemical synthesis, and advanced materials. Visit www.nanonex.com for additional information.